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## PATENT APPLICATION

### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

10/761,099

In re Reissue Application of

Docket No: Q79454

MIYAKE, Hideo, et al.

U.S. Patent No. 6,340,551

Issued: January 22, 2002

Reissue Appln. No.: \_\_\_\_\_

Group Art Unit: \_\_\_\_\_

Confirmation No.: \_\_\_\_\_

Examiner: \_\_\_\_\_

Filed: January 21, 2004

For: POSITIVE TYPE PHOTOSENSITIVE IMAGE-FORMING MATERIAL FOR  
USE WITH AN INFRARED LASER

### SUPPLEMENTAL PRELIMINARY AMENDMENT UNDER 37 C.F.R. §1.173(b)

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Prior to examination, kindly amend the claims of the above-identified reissue application as follows: